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APPLICATION NO. FILING DATE		ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/997,882	11/30/2001		Siang Ping Kwok	TI-29745	4230	
23494	7590	12/05/2003		EXAMINER		
TEXAS IN P O BOX 65		ENTS INCORPOR S 3999	ROSE, ROBERT A			
DALLAS, TX 75265				ART UNIT	PAPER NUMBER	
	٠		•	3723		
			DATE MAILED: 12/05/2003	$\mathcal{G}$		

Please find below and/or attached an Office communication concerning this application or proceeding.

## BEST AVAILABLE COPY

## Office Action Summary

Application No. 09/997,882

Applicant(s)

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Kwok

1	1		Examiner	Art Unit					
1	<i> </i> _		Robert Rose	3723					
1	] riod	The MAILING DATE of this communication appears on the cover sheet with the correspondence address							
\/\1	A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION								
) - - -	Exter mailir If the If NO Failur Any r	nsions of time may be available under the provisions of 37 CFR 1.136 (a). In ng date of this communication. a period for reply specified above is less than thirty (30) days, a reply within the period for reply is specified above, the maximum statutory period will apply a re to reply within the set or extended period for reply will, by statute, cause the reply received by the Office later than these months after the price.	ne statutory minimum of thirty (30) days will be and will expire SIX (6) MONTHS from the mailing	considered timely.					
	tus	· · · · · · · · · · · · · · · · · · ·	They red	uce any					
1	<b>X</b>	Responsive to communication(s) filed on Oct 6, 200	03						
<b>2</b> a		This action is <b>FINAL</b> . 2b) 💢 This acti		<del></del>	•				
3		·	Yount for formal	ution as to the	e merits is				
Dis	osi	ition of Claims	Caudyle, 1935 C.D. 11, 453 C	7.G. 213.					
4)	X	Claim(s) <u>1-16</u>	\is/are	pending in the	application				
	4	1a) Of the character of the co	•						
5)		Claim(s)	·	loso alla	om consideration.				
6)	X	Claim(s) 1-6	is	/are allowed.					
7)		Claim(s)	IS	/are rejected.	. :				
8)		Claimstion Papers	oro pubiose de	/are objected t	to.				
۱pp	lica	tion Papers	are subject to restriction	on and/or elec	tion requirement.				
9)		The specification is objected to by the Examiner.	•						
10)		The drawing(s) filed on is/are a	accepted or b) objected	to by the Evan	ninor .				
		Applicant may not request that any objection to the dra	wing(s) he hold in about a co		i i				
1)[	ا_	the proposed drawing correction filed on	is: a) □ approved b)	disapprove	d by the Examiner.				
2)[	_	to approved, corrected drawings are required in reply to	this Office action.						
		The oath or declaration is objected to by the Examine under 35 U.S.C. §§ 119 and 120	er.						
<b>3</b> )[	ı	Acknowledgement is made of a claim for foreign prior	rity under 35 H.S.C. S. 110/-> /-						
а	) 🗆	All b)□ Some* c)□ None of:	y dilder 35 0.3.C. 9 119(a)-(d	) or (t)					
	1	. Certified copies of the priority documents have t	been received.						
		. ☐ Certified copies of the priority documents have t	Deen received in Application No.						
*	3. See	application from the International Business	ments have been received in thi	is National Sta	ge .				
4)[	] 4	of the c	ertified copies not received						
-a)		Acknowledgement is made of a claim for domestic pri	iority under 35 U.S.C. § 119(e).						
5)[	] 🗚	The translation of the foreign language provisional alacknowledgement is made of a claim for domestic pri	pplication has been received.		·				
-	IIIGII	irisi .	ority under 35 U.S.C. §§ 120 ar	nd/or 121.					
		e of References Cited (PTO-892) 4)	Interview Summary (PTO-413) Paper No(s)						
		e of Draftsperson's Patent Drawing Review (PTO-948) 5)	Notice of Informal Patent Application (PTO-						
<u>ا</u> ت	nom	nation Disclosure Statement(s) (PTO-1449) Paper No(s)	Other:						

Art Unit: 3723

## **DETAILED ACTION**

- 1. Applicant's election without traverse of Group I(claims 1-6) in Paper No. 4 is acknowledged.
- 2. Claims 7-16 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim.

  Election was made without traverse in Paper No. 4.
- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 1, 4, and 6 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tan et al. Tan et al disclose a method of chemical-mechanical polishing comprising substantially all of the subject matter of applicant's claims above. A gap fill material is subjected to cmp, stopping on a nitride film, then the nitride film is removed by a phosphoric acid etch, followed by removal of the underlying layer. The underlying layer is disclosed as being removed by an etching process. It would have been obvious to those of ordinary skill in the art to have supplied an abrasive in addition to the etchant in the final removal step, in order to enhance the removal rate of the etchant solution.

Application/Control Number: 09/997882 Page 3

Art Unit: 3723

5. Claims 2-3, and 5 are objected to as being dependent upon a rejected base claim, but

would be allowable if rewritten in independent form including all of the limitations of the base

claim and any intervening claims.

6. The prior art made of record and not relied upon is considered pertinent to applicant's

disclosure. Lee et al is cited of interest to show etching with phosphoric acid to remove a nitride

stop layer, following a cmp step. Lyons et al is cited to show performing cmp to a stop layer,

followed by stripping of the stop layer.

7. Any inquiry concerning this communication should be directed to Robert Rose at

telephone number (703) 308-1360.

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November 25, 2003.

PROBERT A. ROSE
PRIMARY EXAMINER

ARTUNIT 329

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